Preferred Device

Power MOSFET 20 Amps, 30 Volts, Logic Level

N-Channel DPAK

This advanced Power MOSFET is designed to withstand high energy in the avalanche and commutation modes. This energy efficient design also offers a drain—to—source diode with a fast recovery time. Designed for low voltage, high speed switching applications in power supplies, converters and PWM motor controls, these devices are particularly well suited for bridge circuits where diode speed and commutating safe operating areas are critical and offer additional safety margin against unexpected voltage transients.

Features

- Avalanche Energy Specified
- Source-to-Drain Diode Recovery Time Comparable to a Discrete Fast Recovery Diode
- Diode is Characterized for Use in Bridge Circuits
- I_{DSS} and V_{DS(on)} Specified at Elevated Temperature
- Pb-Free Packages are Available

MAXIMUM RATINGS (T_C = 25°C unless otherwise noted)

Rating	Symbol	Value	Unit	
Drain-Source Voltage	V _{DSS}	30	Vdc	
Drain–Gate Voltage ($R_{GS} = 1.0 \text{ M}\Omega$)	V_{DGR}	30	Vdc	
Gate–Source Voltage – Continuous – Non–Repetitive (t _p ≤ 10 ms)	V _{GS} V _{GSM}	±15 ± 20	Vdc Vpk	
Drain Current – Continuous – Continuous @ 100°C – Single Pulse (t _p ≤ 10 μs)	I _D I _D I _{DM}	20 16 60	Adc Apk	
Total Power Dissipation Derate above 25°C Total Power Dissipation @ T _C = 25°C (Note 2)	P _D	74 0.6 1.75	W/°C	
Operating and Storage Temperature Range	T _J , T _{stg}	-55 to 150	°C	
Single Pulse Drain–to–Source Avalanche Energy – Starting $T_J = 25^{\circ}\text{C}$ ($V_{DD} = 25 \text{ Vdc}, V_{GS} = 5.0 \text{ Vdc}, Peak$ $I_L = 20 \text{ Apk}, L = 1.0 \text{ mH}, R_G = 25 \Omega$)	E _{AS}	200	mJ	
Thermal Resistance - Junction-to-Case - Junction-to-Ambient (Note 1) - Junction-to-Ambient (Note 2)	$egin{array}{c} R_{ heta JC} \ R_{ heta JA} \ R_{ heta JA} \end{array}$	1.67 100 71.4	°C/W	
Maximum Lead Temperature for Soldering Purposes, 1/8" from case for 10 seconds	T _L	260	°C	

Stresses exceeding Maximum Ratings may damage the device. Maximum Ratings are stress ratings only. Functional operation above the Recommended Operating Conditions is not implied. Extended exposure to stresses above the Recommended Operating Conditions may affect device reliability.

- 1. When surface mounted to an FR-4 board using the minimum recommended nad size.
- 2. When surface mounted to an FR-4 board using the 0.5 sq.in. drain pad size.

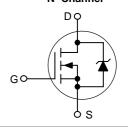


ON Semiconductor®

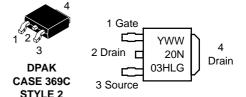
http://onsemi.com

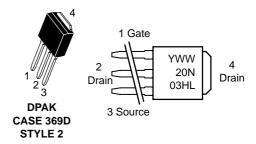
V _{(BR)DSS}	R _{DS(on)} TYP	I _D MAX
30 V	30 mΩ@5.0 V	20 A (Note 1)

N-Channel



MARKING DIAGRAM & PIN ASSIGNMENTS





Y = Year

WW = Work Week

20N03HL = Device Code

G = Pb-Free Package

ORDERING INFORMATION

See detailed ordering and shipping information in the package dimensions section on page 7 of this data sheet.

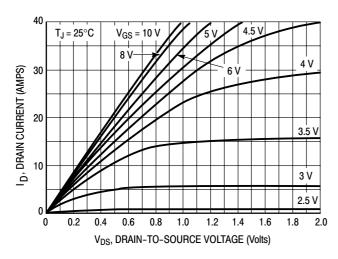
Preferred devices are recommended choices for future use and best overall value.

ELECTRICAL CHARACTERISTICS ($T_J = 25^{\circ}C$ unless otherwise noted)

Characteristic Symbol Min Typ Max Unit					Unit	
OFF CHARACTERISTICS	- Cylliddi		1,712	mux	Oiiit	
Drain-to-Source Breakdown Vo	Itage $(C_{pk} \ge 2.0)$ (Note 5)	Vannon				Vdc
$(V_{GS} = 0 \text{ Vdc}, I_D = 250 \mu\text{Adc})$	$V_{(BR)DSS}$	30	_	_		
Temperature Coefficient (Positive		-	43	_	mV/°C	
Zero Gate Voltage Drain Current	I_{DSS}			10	μAdc	
$(V_{DS} = 30 \text{ Vdc}, V_{GS} = 0 \text{ Vdc})$ $(V_{DS} = 30 \text{ Vdc}, V_{GS} = 0 \text{ Vdc},$		_	_	100		
Gate-Body Leakage Current (V _{GS} = ±15 Vdc, V _{DS} = 0 Vdc	c)	I _{GSS}	_	_	100	nAdc
ON CHARACTERISTICS (Note						
Gate Threshold Voltage	(C _{pk} ≥ 2.0) (Note 5)	V _{GS(th)}				Vdc
$(V_{DS} = V_{GS}, I_{D} = 250 \mu Adc)$	·	CO(iii)	1.0	1.5 5.0	2.0	mV/°C
Threshold Temperature Coefficient	, ,		_	5.0	_	
Static Drain-to-Source On-Res ($V_{GS} = 4.0 \text{ Vdc}$, $I_D = 10 \text{ Adc}$)	istance $(C_{pk} \ge 2.0)$ (Note 5)	$R_{DS(on)}$	_	0.034	0.040	Ω
$(V_{GS} = 1.0 \text{ Vdc}, I_D = 10 \text{ Adc})$				0.030	0.035	
Drain-to-Source On-Voltage (V	_{GS} = 5.0 Vdc)	V _{DS(on)}				Vdc
(I _D = 20 Adc) (I _D = 10 Adc, T _J = 125°C)			_	0.55	0.8 0.7	
Forward Transconductance		9FS				mhos
$(V_{DS} = 5.0 \text{ Vdc}, I_{D} = 10 \text{ Adc})$		313	10	13	_	
DYNAMIC CHARACTERISTICS	i e e e e e e e e e e e e e e e e e e e					
Input Capacitance		C_{iss}	-	880	1260	pF
Output Capacitance	$(V_{DS} = 25 \text{ Vdc}, V_{GS} = 0 \text{ Vdc}, f = 1.0 \text{ MHz})$	C _{oss}	-	300	420	
Transfer Capacitance		C _{rss}	-	80	150	
SWITCHING CHARACTERISTIC	CS (Note 4)					
Turn-On Delay Time		$t_{d(on)}$	_	13	20	ns
Rise Time	(V _{DD} = 15 Vdc, I _D = 20 Adc,	t _r	-	212	238	
Turn-Off Delay Time	$V_{GS} = 5.0 \text{ Vdc}, R_G = 9.1 \Omega$	$t_{d(off)}$	_	23	40	
Fall Time		t _f	-	84	140	
Gate Charge (See Figure 8)		Q _T	_	13.4	18.9	nC
	()/ 24 \/do 20 \/do \/ 5 0 \/do\	Q ₁	_	3.0 –		
	$(V_{DS} = 24 \text{ Vdc}, I_{D} = 20 \text{ Adc}, V_{GS} = 5.0 \text{ Vdc})$	Q ₂	_	7.3	_	
		Q_3	-	6.0	_	
SOURCE-DRAIN DIODE CHAR	ACTERISTICS					
Forward On–Voltage	(I _S = 20 Adc, V _{GS} = 0 Vdc)	V_{SD}		0.05	4.4	Vdc
(C _{pk} ≥ 2.0) (Note 5)	$(I_S = 20 \text{ Adc}, V_{GS} = 0 \text{ Vdc}, T_J = 125 ^{\circ}\text{C})$		_	0.95 0.87	1.1	
Reverse Recovery Time		t _{rr}	_	33	_	ns
(See Figure 15)		t _a	_	23	_	1
	$(I_S = 20 \text{ Adc}, V_{GS} = 0 \text{ Vdc}, dI_S/dt = 100 \text{ A/}\mu\text{s})$	t _b	_	10	_	1
Reverse Recovery Stored Charge		Q _{RR}	-	33	-	μC
INTERNAL PACKAGE INDUCT	ANCE		1	I	<u>I</u>	1
Internal Drain Inductance	L _D				nH	
(Measured from the drain lea		_	4.5	-		
Internal Source Inductance	L _S		7.5		nΗ	
(Measured from the source le		_	7.5	_		

- 3. Pulse Test: Pulse Width \leq 300 μ s, Duty Cycle \leq 2%. 4. Switching characteristics are independent of operating junction temperature. 5. Reflects typical values. C_{pk} = Absolute Value of Spec (Spec–AVG/3.516 μ A).

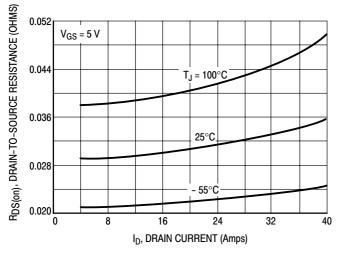
TYPICAL ELECTRICAL CHARACTERISTICS



 $V_{DS} \geq 10 \; V$ I_D, DRAIN CURRENT (AMPS) 100°C 25°C $T_J = -55^{\circ}C$ 0 1.0 1.4 1.8 2.6 3.0 3.4 3.8 V_{GS}, GATE-TO-SOURCE VOLTAGE (Volts)

Figure 1. On-Region Characteristics

Figure 2. Transfer Characteristics



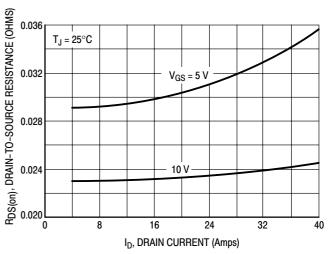
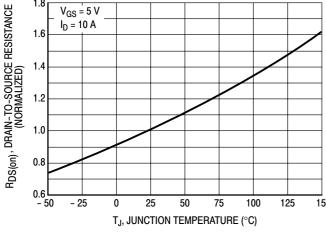
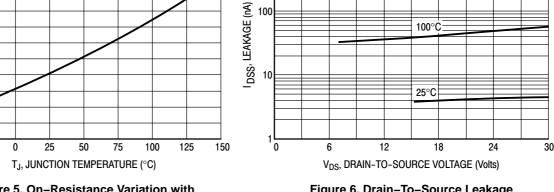


Figure 3. On-Resistance versus Drain Current and Temperature

Figure 4. On-Resistance versus Drain Current and Gate Voltage

 $T_J = 125^{\circ}C$





1000

 $V_{GS} = 0 V$

Figure 5. On-Resistance Variation with **Temperature**

Figure 6. Drain-To-Source Leakage **Current versus Voltage**

POWER MOSFET SWITCHING

Switching behavior is most easily modeled and predicted by recognizing that the power MOSFET is charge controlled. The lengths of various switching intervals (Δt) are determined by how fast the FET input capacitance can be charged by current from the generator.

The published capacitance data is difficult to use for calculating rise and fall because drain–gate capacitance varies greatly with applied voltage. Accordingly, gate charge data is used. In most cases, a satisfactory estimate of average input current ($I_{G(AV)}$) can be made from a rudimentary analysis of the drive circuit so that

$$t = Q/I_{G(AV)}$$

During the rise and fall time interval when switching a resistive load, V_{GS} remains virtually constant at a level known as the plateau voltage, V_{SGP} Therefore, rise and fall times may be approximated by the following:

$$t_r = Q_2 \ x \ R_G/(V_{GG} - V_{GSP})$$

$$t_f = Q_2 \ x \ R_G/V_{GSP}$$

where

 V_{GG} = the gate drive voltage, which varies from zero to V_{GG} R_G = the gate drive resistance

and Q2 and VGSP are read from the gate charge curve.

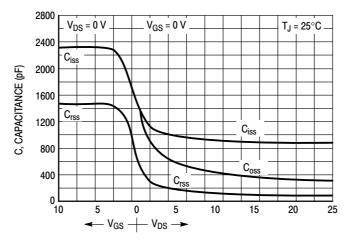
During the turn-on and turn-off delay times, gate current is not constant. The simplest calculation uses appropriate values from the capacitance curves in a standard equation for voltage change in an RC network. The equations are:

$$\begin{split} t_{d(on)} &= R_G \; C_{iss} \; In \; [V_{GG}/(V_{GG} - V_{GSP})] \\ t_{d(off)} &= R_G \; C_{iss} \; In \; (V_{GG}/V_{GSP}) \end{split}$$

The capacitance (C_{iss}) is read from the capacitance curve at a voltage corresponding to the off–state condition when calculating $t_{d(on)}$ and is read at a voltage corresponding to the on–state when calculating $t_{d(off)}$.

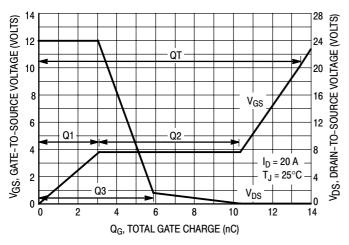
At high switching speeds, parasitic circuit elements complicate the analysis. The inductance of the MOSFET source lead, inside the package and in the circuit wiring which is common to both the drain and gate current paths, produces a voltage at the source which reduces the gate drive current. The voltage is determined by Ldi/dt, but since di/dt is a function of drain current, the mathematical solution is complex. The MOSFET output capacitance also complicates the mathematics. And finally, MOSFETs have finite internal gate resistance which effectively adds to the resistance of the driving source, but the internal resistance is difficult to measure and, consequently, is not specified.

The resistive switching time variation versus gate resistance (Figure 9) shows how typical switching performance is affected by the parasitic circuit elements. If the parasitics were not present, the slope of the curves would maintain a value of unity regardless of the switching speed. The circuit used to obtain the data is constructed to minimize common inductance in the drain and gate circuit loops and is believed readily achievable with board mounted components. Most power electronic loads are inductive; the data in the figure is taken with a resistive load, which approximates an optimally snubbed inductive load. Power MOSFETs may be safely operated into an inductive load; however, snubbing reduces switching losses.



GATE-TO-SOURCE OR DRAIN-TO-SOURCE VOLTAGE (Volts)

Figure 7. Capacitance Variation



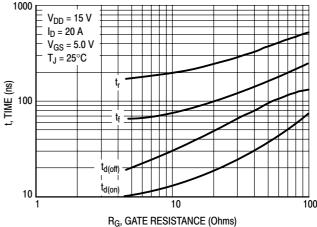


Figure 8. Gate-To-Source and Drain-To-Source
Voltage versus Total Charge

Figure 9. Resistive Switching Time Variation versus Gate Resistance

DRAIN-TO-SOURCE DIODE CHARACTERISTICS

The switching characteristics of a MOSFET body diode are very important in systems using it as a freewheeling or commutating diode. Of particular interest are the reverse recovery characteristics which play a major role in determining switching losses, radiated noise, EMI and RFI.

System switching losses are largely due to the nature of the body diode itself. The body diode is a minority carrier device, therefore it has a finite reverse recovery time, $t_{\rm rr}$, due to the storage of minority carrier charge, Q_{RR} , as shown in the typical reverse recovery wave form of Figure 12. It is this stored charge that, when cleared from the diode, passes through a potential and defines an energy loss. Obviously, repeatedly forcing the diode through reverse recovery further increases switching losses. Therefore, one would like a diode with short $t_{\rm rr}$ and low Q_{RR} specifications to minimize these losses.

The abruptness of diode reverse recovery effects the amount of radiated noise, voltage spikes, and current ringing. The mechanisms at work are finite irremovable circuit parasitic inductances and capacitances acted upon by

high di/dts. The diode's negative di/dt during t_a is directly controlled by the device clearing the stored charge. However, the positive di/dt during t_b is an uncontrollable diode characteristic and is usually the culprit that induces current ringing. Therefore, when comparing diodes, the ratio of t_b/t_a serves as a good indicator of recovery abruptness and thus gives a comparative estimate of probable noise generated. A ratio of 1 is considered ideal and values less than 0.5 are considered snappy.

Compared to ON Semiconductor standard cell density low voltage MOSFETs, high cell density MOSFET diodes are faster (shorter t_{rr}), have less stored charge and a softer reverse recovery characteristic. The softness advantage of the high cell density diode means they can be forced through reverse recovery at a higher di/dt than a standard cell MOSFET diode without increasing the current ringing or the noise generated. In addition, power dissipation incurred from switching the diode will be less due to the shorter recovery time and lower switching losses.

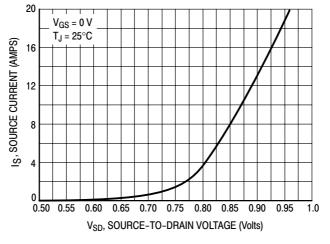


Figure 10. Diode Forward Voltage versus Current

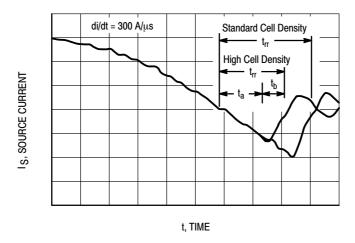


Figure 11. Reverse Recovery Time (t_{rr})

SAFE OPERATING AREA

The Forward Biased Safe Operating Area curves define the maximum simultaneous drain–to–source voltage and drain current that a transistor can handle safely when it is forward biased. Curves are based upon maximum peak junction temperature and a case temperature ($T_{\rm C}$) of 25°C. Peak repetitive pulsed power limits are determined by using the thermal response data in conjunction with the procedures discussed in AN569, "Transient Thermal Resistance – General Data and Its Use."

Switching between the off–state and the on–state may traverse any load line provided neither rated peak current (I_{DM}) nor rated voltage (V_{DSS}) is exceeded, and that the transition time (t_r , t_f) does not exceed 10 μs . In addition the total power averaged over a complete switching cycle must not exceed ($T_{J(MAX)} - T_C$)/($R_{\theta JC}$).

A power MOSFET designated E-FET can be safely used in switching circuits with unclamped inductive loads. For reliable operation, the stored energy from circuit inductance dissipated in the transistor while in avalanche must be less than the rated limit and must be adjusted for operating conditions differing from those specified. Although industry practice is to rate in terms of energy, avalanche energy capability is not a constant. The energy rating decreases non–linearly with an increase of peak current in avalanche and peak junction temperature.

Although many E–FETs can withstand the stress of drain–to–source avalanche at currents up to rated pulsed current (I_{DM}), the energy rating is specified at rated continuous current (I_{D}), in accordance with industry custom. The energy rating must be derated for temperature as shown in the accompanying graph (Figure 13). Maximum energy at currents below rated continuous I_{D} can safely be assumed to equal the values indicated.

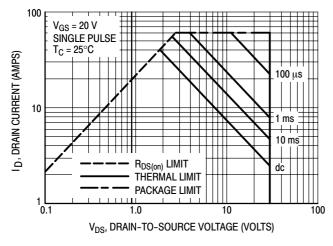


Figure 12. Maximum Rated Forward Biased Safe Operating Area

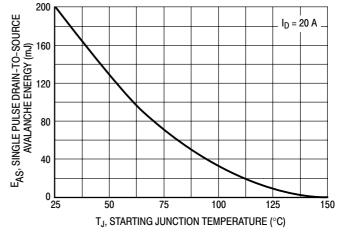


Figure 13. Maximum Avalanche Energy versus Starting Junction Temperature

TYPICAL ELECTRICAL CHARACTERISTICS

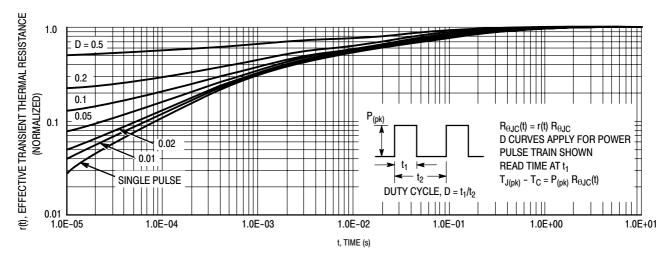


Figure 14. Thermal Response

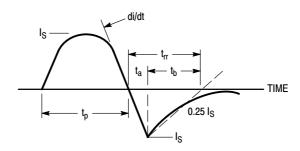


Figure 15. Diode Reverse Recovery Waveform

ORDERING INFORMATION

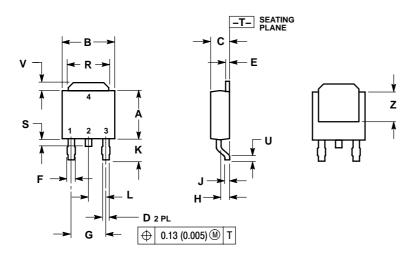
Device	Package	Shipping [†]
MTD20N03HDL	DPAK	75 Units / Rail
MTD20N03HDLG	DPAK (Pb-Free)	75 Units / Rail
MTD20N03HDL1	DPAK Straight Lead	75 Units / Rail
MTD20N03HDLT4	DPAK	2500 / Tape & Reel
MTD20N03HDLT4G	DPAK (Pb-Free)	2500 / Tape & Reel

[†]For information on tape and reel specifications, including part orientation and tape sizes, please refer to our Tape and Reel Packaging Specifications Brochure, BRD8011/D.

PACKAGE DIMENSIONS

DPAK

CASE 369C-01 ISSUE O

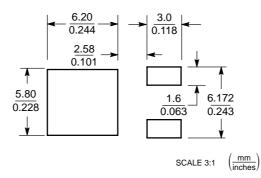


- NOTES: 1. DIMENSIONING AND TOLERANCING PER ANSI Y14.5M, 1982. 2. CONTROLLING DIMENSION: INCH.

	INCHES		MILLIMETERS	
DIM	MIN	MAX	MIN	MAX
Α	0.235	0.245	5.97	6.22
В	0.250	0.265	6.35	6.73
С	0.086	0.094	2.19	2.38
D	0.027	0.035	0.69	0.88
E	0.018	0.023	0.46	0.58
F	0.037	0.045	0.94	1.14
G	0.180	BSC	4.58 BSC	
Н	0.034	0.040	0.87	1.01
J	0.018	0.023	0.46	0.58
K	0.102	0.114	2.60	2.89
L	0.090	BSC	2.29	BSC
R	0.180	0.215	4.57	5.45
S	0.025	0.040	0.63	1.01
U	0.020		0.51	
٧	0.035	0.050	0.89	1.27
Z	0.155		3.93	

- STYLE 2: PIN 1. GATE 2. DRAIN 3. SOURCE 4. DRAIN

SOLDERING FOOTPRINT*

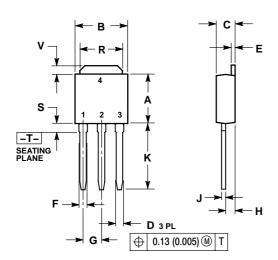


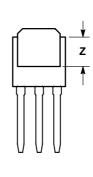
^{*}For additional information on our Pb–Free strategy and soldering details, please download the ON Semiconductor Soldering and Mounting Techniques Reference Manual, SOLDERRM/D.

PACKAGE DIMENSIONS

DPAK-3 (SINGLE GAUGE)

CASE 369D-01 **ISSUE B**





NOTES:

- 1. DIMENSIONING AND TOLERANCING PER ANSI Y14.5M, 1982
- CONTROLLING DIMENSION: INCH.

	INCHES		MILLIMETERS		
DIM	MIN	MAX	MIN	MAX	
Α	0.235	0.245	5.97	6.35	
В	0.250	0.265	6.35	6.73	
С	0.086	0.094	2.19	2.38	
D	0.027	0.035	0.69	0.88	
Е	0.018	0.023	0.46	0.58	
F	0.037	0.045	0.94	1.14	
G	0.090 BSC		2.29	2.29 BSC	
Н	0.034	0.040	0.87	1.01	
J	0.018	0.023	0.46	0.58	
K	0.350	0.380	8.89	9.65	
R	0.180	0.215	4.45	5.45	
S	0.025	0.040	0.63	1.01	
٧	0.035	0.050	0.89	1.27	
Z	0.155		3.93		

STYLE 2:

- PIN 1. GATE 2. DRAIN
 - SOURCE 3. DRAIN

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